

Title (en)

METHOD OF INCREASING THE ALPHA-AMYLASE-RESISTANT STARCH CONTENT (RS CONTENT) OF A POLYSACCHARIDE, POLYSACCHARIDES, THE USE THEREOF AND FOOD CONTAINING SAID POLYSACCHARIDES

Title (de)

VERFAHREN ZUR ERHÖHUNG DES GEHALTES AN ALPHA AMYLASE-RESISTENTER STÄRKE(RS-GEHALT) EINES POLYSACCHARIDS, POLYSACCHARIDE, DEREN VERWENDUNG UND LEBENSMITTEL MIT DIESEN POLYSACCHARIDEN

Title (fr)

PROCEDE POUR AUGMENTER LA TENEUR EN AMIDON RESISTANT A L'ALPHA-AMYLASE (TENEUR EN AMIDON RESISTANT) D'UN POLYSACCHARIDE, POLYSACCHARIDES, LEUR UTILISATION, ET PRODUITS ALIMENTAIRES CONTENANT CES POLYSACCHARIDES

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Abstract (en)

[origin: WO0142309A2] The invention relates to a method of increasing the alpha -amylase-resistant starch content (RS content) of a polysaccharide. The inventive method is characterized by incubating the polysaccharide used with less than an equivalent weight of water, cooling it, optionally drying it and obtaining a polysaccharide that has an increased RS content vis-à-vis the polysaccharide used.

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CPC (source: EP US)

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Citation (search report)

See references of WO 0142309A2

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- EP 1088832 A1 20010404 - NAT STARCH CHEM INVEST [US]
- US 5902410 A 19990511 - CHIU CHUNG-WAI [US], et al

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